# 13.2: A Floating-Gate OTFT-Driven AMOLED Pixel Circuit for Variation and Degradation Compensation in Large-Sized Flexible Displays

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#### **Abstract**

For the first time, we demonstrate an AMOLED pixel circuit on a 13- $\mu$ m thick plastic film that applies floating-gate organic TFTs (FG-OTFTs) to compensate for OTFT driving current variations and OLED efficiency degradations. By programming  $V_{TH}$  of the FG-OTFTs, we can realize less than 5% spatial non-uniformity and 85% power reduction compared with voltage-programming.

# 1. Introduction

AMOLED displays have attracted much attention recently because of their excellent image quality and wide viewing angle [1-2]. Organic TFT (OTFT) is considered as a strong candidate for pixel circuits of large-size flexible displays, because of its mechanical flexibility and compatibility with the low-cost printing process at room temperature [3-4]. OTFT-driven AMOLED displays, therefore, are a promising solution for realizing next-generation large-size, light-weight, and mechanically robust flexible displays. To print a large number of OTFTs on large-area flexible substrates with high-uniformity, however, is very challenging and has become the major bottleneck for realizing large-size OTFT-driven AMOLED flexible displays.

In this paper, for the first time, we demonstrate a FG-OTFT-driven AMOLED pixel circuit for flexible displays as shown in Fig. 1. The pixel circuit enables electrical feedback to tune  $V_{TH}$  of the FG-OTFT for compensating OTFT variations and OLED efficiency degradations. Unlike voltage-programming or current-programming [5-6] that require  $V_{TH}$  compensation in every frame time, the programmed  $V_{TH}$  in our FG-OTFTs can retain for tens of hours and no further  $V_{TH}$  programming is needed within the retention time. The proposed work, therefore, has several key advantages over conventional methods including: 1) low power-consumption by eliminating  $V_{TH}$  compensation cycle in the frame time, 2) compensation for both OTFT non-uniformity and OLED

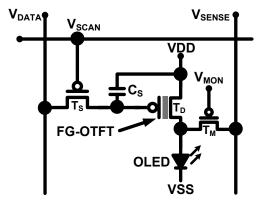


Figure 1: Proposed AMOLED 3T-1C pixel-circuit.

efficiency degradations, and 3) higher aperture ratio and yield because of reduced transistor counts (3T-1C).

## 1.1. Floating-Gate Organic TFTs

Fig. 2 shows the cross-section of a 20V FG-OTFT. The channel length L is 20  $\mu$ m and the organic semiconductor in our p-type FG-OTFT is DNTT [7] with carrier mobility of 0.7 cm²/Vs. While the 20V FG-OTFT can work as a normal OTFT with -20V gate-voltage  $V_{GS}$ , its  $V_{TH}$  can be adjusted by applying high-voltage electrical stresses to the gate terminal. As shown in Fig. 3, when the source and drain terminals of a FG-OTFT are grounded and no drain-source current is conducting, the electron holes can be injected from the Parylene gate insulator to the Au floating gate by applying a pulsed high voltage such as -60V to its gate terminal. These injected holes can be kept in the Au floating-gate and reduce electrical field from the gate voltage to the organic semiconductor. The effective  $V_{TH}$  of the FG-OTFT is therefore increased until the injected electron holes completely escape. More details about our FG-OTFTs can be found elsewhere in [8].

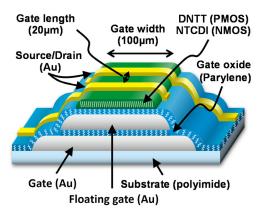


Figure 2: Cross section of a 20V FG-OTFT.

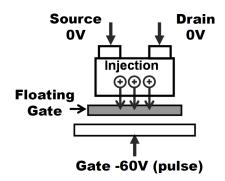


Figure 3: Working principle of a FG-OTFT.

#### 1.2. Pixel Structure

Fig. 4 shows typical voltages of  $V_{DATA}$ ,  $V_{SCAN}$ ,  $V_{MON}$ , and  $V_{SENSE}$ in Fig. 1 for monitoring FG-OTFT non-uniformity and OLED efficiency degradations, as well as programming V<sub>TH</sub> of the FG-OTFT. In order to monitor the driving current of T<sub>D</sub> as shown in Fig. 4 without being affected by  $V_{\text{TH}}$  variations of  $T_{\text{M}},\,V_{\text{CAL}}$  was set sufficiently close to  $V_{TH}$  of  $T_D$  while  $V_G$  of  $T_M$  was set to a higher voltage such as -40V to keep the on-resistance of T<sub>D</sub> much higher than that of T<sub>M</sub> as shown in Fig. 4(a). Fig. 5 shows SPICEsimulated T<sub>D</sub> current measurement errors due to V<sub>TH</sub> variations of T<sub>M</sub>. We can find that the current measurement error can be minimized to less than 5% even under 20%  $V_{TH}$  variations of  $T_{M}$ because the measured current was mainly determined by T<sub>D</sub> in the saturation region rather than  $T_{M}$  in the linear region. Fig. 4(b) shows the configuration of monitoring OLED efficiency degradation.  $T_D$  was switched off by setting  $V_{GS}$  of  $T_D$  to be  $10 \mbox{\em V}$ and V<sub>SENSE</sub> was set close to V<sub>TH</sub> of OLED (~6V) to minimize V<sub>DS</sub> of T<sub>M</sub> for reducing current measurement errors. The OLED efficiency degradation can then be estimated by measuring V<sub>TH</sub> of OLED at a given current. V<sub>DATA</sub> and V<sub>TH</sub> of T<sub>D</sub> can be adjusted accordingly to compensate for OLED efficiency degradations.

Fig. 4(c) shows the configuration of  $V_{TH}$  programming for  $T_D$ . A pulsed electrical stress -60V was applied to the gate terminal of  $T_D$  through  $T_S$ .  $V_D$  and  $V_S$  of  $T_D$  were both set to 0V during  $V_{TH}$ 

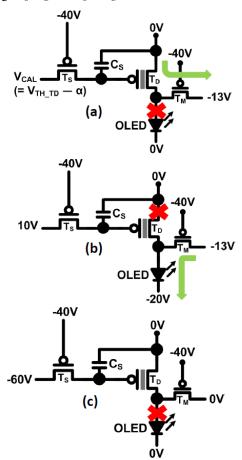


Figure 4: (a) Monitoring FG-OTFT driving current, (b) monitoring OLED efficiency degradations, and (c) applying electrical stress for  $V_{TH}$  programming.  $W_{TD}$  = 6 cm,  $W_{TM}$ = $W_{TS}$ =0.3 cm, and  $C_S$ =2pF in our pixels.

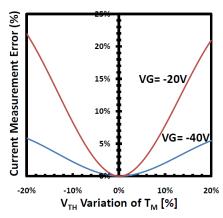


Figure 5: SPICE-simulated current measurement error due to  $V_{TH}$  variations of  $T_{M}$ .  $V_{G}$  is the gate voltage of  $T_{M}$ .

programming such that no current is conducting through  $T_D$ . The measurement results and the scheme of  $V_{\rm TH}$  programming for minimizing non-uniformity and power consumption are followed.

# 2. Measurement Results

# 2.1. V<sub>TH</sub> Programming

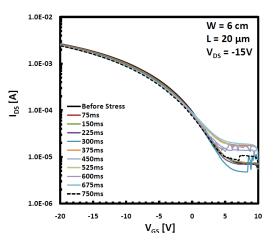


Figure 6:  $V_{TH}$  programming process for a FG-OTFT with (-60V, 75ms) step size of electrical stress.

To perform quantitative analysis of V<sub>TH</sub> programming, we applied a digital control method by fixing the stress voltage V<sub>STRESS</sub> to -60V and varying the number of stress pulses and the pulse-width for V<sub>TH</sub> control. Fig. 6 shows the measurement results of the FG-OTFT driving currents during  $V_{\text{TH}}$  programming process with (-60V, 75ms) stress conditions. The device size of the FG-OTFT was made large to provide sufficient driving currents for our OLEDs to achieve peak brightness greater than 200 cd/m<sup>2</sup>. From Fig. 6 we can observe that  $V_{\text{TH}}$  increases with the stress time due to injected electron holes in the floating-gate. The programmed V<sub>TH</sub> can retain for tens of hours until full recovery to its original  $V_{TH}$ . Since  $V_{DS}$  of the FG-OTFT was kept to 0V during  $V_{TH}$ programming, the measured drain-source current I<sub>DS</sub> of T<sub>D</sub> during V<sub>TH</sub> programming was lower than 1nA, which was six orders or less than its saturation current and therefore consumed negligible power compared with OLED driving.

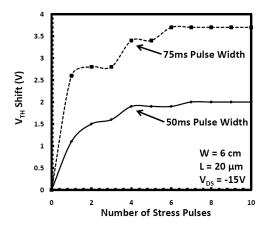


Figure 7: The relationship between  $V_{TH}$  shifts and pulse.

Fig. 7 shows the relationship among  $\Delta V_{TH}$ , stress pulse width, and stress time with -60V stress voltage. Here  $V_{TH}$  is defined as (W/L x 50nA) using the constant current method, where W is the channel width and L is the channel length. We can learn from Fig. 7 that larger stress voltage  $V_{STRESS}$  and longer stress time  $T_{STRESS}$  can result in greater  $V_{TH}$  shifts. The measured  $\Delta V_{TH}$  can be fitted to Eqn.1 where  $\alpha$  and  $\beta$  are fitting parameters.

$$\Delta V_{TH} = V_{Stress}^{\alpha} \log_{\beta}(T_{Stress})$$
 (1)

# 2.2. Variation Compensation for Pixel Circuit

To demonstrate variation compensation by  $V_{TH}$  programming, we prepared six identical FG-OTFT-driven AMOLED pixels in a 2x3 array on the same polyimide plastic film. In order to illustrate the effects of electrical stress, Fig. 8 shows  $I_{DRIVE}$ - $V_{DATA}$  plots of two AMOLED pixels and the inset shows the variations before and after applying electrical stress. We can see that the driving current difference was larger than 15% initially and this difference was minimized to less than 2% after applying total 525ms stress with (-60V, 75ms) stress pulses. Note that the stress conditions can be further optimized to meet the requirements of  $V_{TH}$  control resolution, total stress time, and required spatial uniformity. The  $V_{TH}$  programming scheme for variations and degradations compensation is illustrated using a flowchart as shown in Fig. 9.  $V_{TH}$  monitoring and electrical stress are provided through external

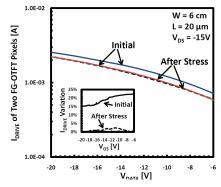


Figure 8: Variation compensations for two neighboring AMOLED pixels (blue and red solid-lines). Black broken-line shows the after-stress  $I_{DRIVE}$  while blue solid-line shows the before-stress  $I_{DRIVE}$  of the identical AMOLED pixel.

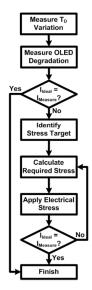


Figure 9: Flowchart of measuring and compensating OTFT variations and OLED degradations.

circuitry.  $T_D$  in Fig. 9 represents the FG-OTFT-based OLED driver as shown in Fig. 4. Fig. 10 shows the compensation results for all six AMOLED pixels. The broken lines represent the initial driving currents provided by FG-OTFTs before-stress while solid lines are driving currents after  $V_{TH}$  programming, which scheme is illustrated in Fig. 9. The inset of Fig. 10 shows that the driving current variation, represented by standard deviations, was reduced from 14% to less than 5% after  $V_{TH}$  programming. Although here only shows the results for total six pixels, the  $V_{TH}$  programming scheme can be easily applied to all AMOLED pixels in flexible displays for minimizing spatial non-uniformity.

The OLED efficiency degradations can also be compensated by monitoring  $V_{TH}$  of OLEDs at known input currents through  $T_{M}$  as shown in Fig. 4(b), which can be used to indicate the degree of OLED efficiency degradations for  $T_{D}$  current compensations.

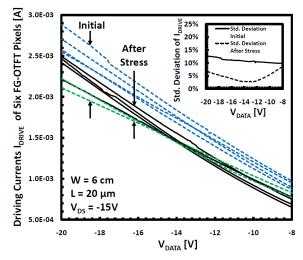


Figure 10: Driving currents  $I_{DRIVE}$  of total six pixels beforestress (broken-line) and after-stress (solid-line). The inset shows the standard deviations of  $I_{DRIVE}$ . Green broken lines show no-need-to-stress pixels due to initially lower driving currents.



Figure 11: Timing diagram for conventional voltage-programming and proposed  $V_{TH}$  programming schemes.  $V_{TH}$  programming process can retain  $V_{TH}$  for tens of hours.

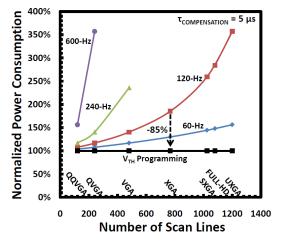


Figure 12: Normalized power consumption  $P_{PIXEL}$  of an AMOLED pixel under different display resolutions and refresh rates using voltage-programming scheme. Proposed  $V_{TH}$  programming is used as the reference for comparisons.

### 2.3. Power Reduction

In addition to variation and degradation compensation, the proposed FG-OTFT pixel circuit also lowers the pixel power consumption  $P_{\text{PIXEL}}$  because of eliminating the  $V_{\text{TH}}$  compensation cycle in the frame time  $\tau_{FRAME}$  ( $\tau_{F}$ ). For conventional compensation schemes such as voltage-programming, V<sub>TH</sub> of the driving TFT is generated and stored in a capacitor that needs to be updated every frame time. In order to ensure that the stored  $V_{\text{TH}}\,\text{is}$ equal or close enough to the real  $V_{\text{TH}}$ , the required compensation time  $\tau_{COMPENSATION}$  ( $\tau_{C}$ ) should be longer than tens of microsecond (µs) [9]. Since  $\tau_C$  reduces the driving time  $\tau_{DRIVING}(\tau_D)$  as illustrated in Eqn. 2 for a given  $\tau_F$  and the compensation power P<sub>COMPENSATION</sub> (P<sub>C</sub>) does not directly contribute to driving the OLED, the required P<sub>PIXEL</sub> for the voltage-programming scheme within the reduced  $\tau_D$  in order to achieve the same peak brightness as the proposed V<sub>TH</sub> programming scheme will therefore increase significantly. Fig. 11 shows the timing diagram and Fig. 12 shows the normalized pixel power consumption PPIXEL for both voltageprogramming and  $V_{TH}$  programming schemes. Note that  $P_{PIXEL}$  in Fig. 12 is calculated by assuming  $\tau_C$  equal to 5 µs and the same average OLED driving currents  $I_{\text{OLED}}$  under the same  $\tau_{\text{F}}$  for both cases. While the proposed  $V_{\text{TH}}$  programming scheme using FG-OTFTs does not require the  $V_{TH}$  compensation cycle and consumes negligible power during the  $V_{TH}$  programming process, the voltage-programming scheme requires 85% power overhead if driven at the XGA resolution with 120-Hz refresh rate. Higher resolutions and refresh rates, as well as longer  $\tau_C$ , will inevitably increase the pixel power consumption due to the reduced  $\tau_D$ . Note that for high refresh rates such as 240-Hz and 600-Hz, higher

resolutions than VGA mode are unable to achieve in the voltage-programming scheme since  $\tau_F$  will be less than 5  $\mu$ s (= $\tau_C$ ).

$$\begin{split} P_{PIXEL} &= P_{COMPENSATION} + P_{PROGRAMMING} + P_{DRIVING} \\ \tau_{DRIVING} &= \tau_{FRAME} - \tau_{COMPENSATION} - \tau_{PROGRAMMING} \end{split} \tag{2}$$

#### 3. Conclusion

In this paper, for the first time, we demonstate a FG-OTFT driven AMOLED pixel circuit on a 13-µm thick polyimide plastic film for compensating OTFT process variations and OLED efficiency degradations. The photo of the proposed FG-OTFT pixel-circuit is shown in Fig. 13. In our test sample, we prepared six identical pixels allocated in a 2x3 array. After applying the electrical stress to the driving FG-OTFTs, the overall spacial non-uniformity of the driving FG-OTFTs was minimized from 14% to be less than 5%. Compared with the conventional voltage-programming compensation scheme, the pixel power consumption can be reduced by 85% for the XGA resolution at 120-Hz referesh rate.

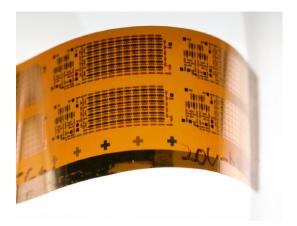


Figure 13: Photo of the FG-OTFT-driven AMOLED pixels. The pixel size is 20.8 mm x 6.6 mm and substrate thickness is 13  $\mu$ m.

### 4. Acknowledgements

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### 5. References

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